

1. Record Nr.	UNINA9910130882203321
Titolo	Silicon carbide . Volume 2 Power devices and sensors [[electronic resource] /] / edited by Peter Friedrichs ... [et al.]
Pubbl/distr/stampa	Weinheim, Germany, : Wiley-VCH, c2010
ISBN	1-283-37038-7 9786613370389 3-527-62908-4 3-527-62907-6
Descrizione fisica	1 online resource (522 p.)
Altri autori (Persone)	FriedrichsPeter
Disciplina	621.381 621.38152
Soggetti	Silicon carbide Semiconductors Electronic books.
Lingua di pubblicazione	Inglese
Formato	Materiale a stampa
Livello bibliografico	Monografia
Note generali	Description based upon print version of record.
Nota di bibliografia	Includes bibliographical references and index.
Nota di contenuto	Silicon Carbide: Volume 2: Power Devices and Sensors; Volume 2 Silicon Carbide: Power Devices and Sensors; Contents; Preface; List of Contributors; Part A View from Industry; 1 Present status and future prospects for electronics in electric vehicles/hybrid electric vehicles and expectations for wide-bandgap semiconductor devices; 1.1 Issues surrounding automobiles; 1.2 Past, present, and future of Toyota hybrid vehicles; 1.3 Newest hybrid vehicle; 1.4 Expectations for wide-bandgap semiconductors in HV inverter applications 1.5 Toyota Group research and development on wide-bandgap semiconductor devices1.6 Conclusions; References; 2 Silicon carbide power-device products - Status and upcoming challenges with a special attention to traditional, nonmilitary industrial applications; 2.1 Introduction; 2.2 SiC in power electronics; 2.3 Summary; References; Part B I Unipolar Devices Schottky Diodes; 3 Effect of an intermediate graphite layer on the electronic properties of metal/SiC contacts; 3.1 Introduction; 3.2 Experimental; 3.3 Results; 3.4 Discussion; 3.5 Conclusions; References

4 Reliability aspects of SiC Schottky diodes 4.1 Introduction; 4.2 Micropipes; 4.3 Avalanche ruggedness by design improvement; 4.4 Product improvement by high performance die attach; 4.5 Reliability test results; 4.6 Summary; References; Part B II JFET; 5 Design, process, and performance of all-epitaxial normally-off SiC JFETs; 5.1 Introduction; 5.2 Advantages of the SiC JFET technology; 5.3 All-epitaxial normally-off SiC DGTJFET design; 5.4 Innovative device process technologies; 5.5 All-epitaxial 1200 V trench 4H-SiC DGTJFET; 5.6 Conclusion; References

6 Extreme temperature 6H-SiC JFET integrated circuit technology 6.1 Introduction; 6.2 Transistors; 6.3 Circuits; 6.4 Summary & future work; References; 7 1200 V SiC vertical-channel-JFETs and cascode switches; 7.1 Introduction; 7.2 Large-area 1200 V 4H-SiC vertical JFET structures; 7.3 Investigation of the suitability of 1200 V normally-off vertical-channel SiC JFETs for power switching applications; 7.4 1200 V normally-off all-SiC VJFET based cascode switch; 7.5 Reliability of the 1200 V normally-off all-SiC VJFET cascode switch; 7.6 Thermal properties of VJFET/cascode

7.7 0.143 cm² active-area 1200 V class vertical-channel JFETs 7.8 Edge termination of large-area vertical-channel JFETs; 7.9 Summary; References; Part B III MOS Interfaces; 8 Alternative techniques to reduce interface traps in n-type 4H-SiC MOS capacitors; 8.1 Introduction; 8.2 Material, processing parameters, and analysis techniques; 8.3 Thermal oxidation in a tungsten lamp furnace combined with a microwave plasma; 8.4 Over-oxidation of N-implanted 4H-SiC; 8.5 Over-oxidation of N-/Al-implanted 4H-SiC; 8.5.1 Material and implantation parameters; 8.5.2 Results and discussion; 8.6 Summary

References

Sommario/riassunto

Silicon Carbide - this easy to manufacture compound of silicon and carbon is said to be THE emerging material for applications in electronics. High thermal conductivity, high electric field breakdown strength and high maximum current density make it most promising for high-powered semiconductor devices. Apart from applications in power electronics, sensors, and NEMS, SiC has recently gained new interest as a substrate material for the manufacture of controlled graphene. SiC and graphene research is oriented towards end markets and has high impact on areas of rapidly growing interest like elect